



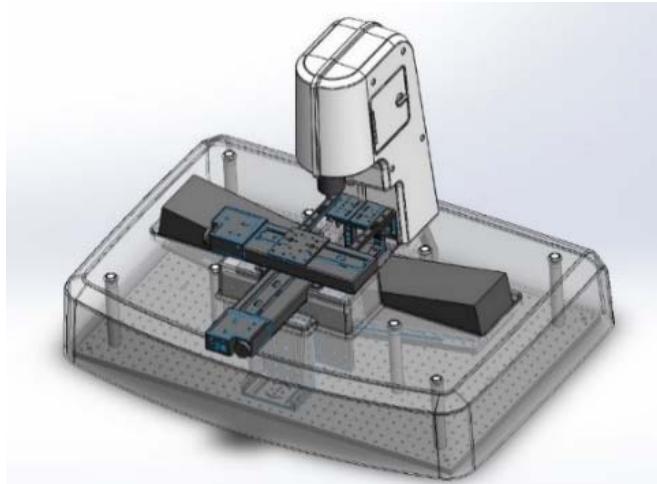
**Automated Performance of On-wafer Calibration and  
Characterization Using Non-Contact Probes**

**TERAPROBES<sup>INC</sup>**

# Fully-automated On-wafer Non-contact Characterization



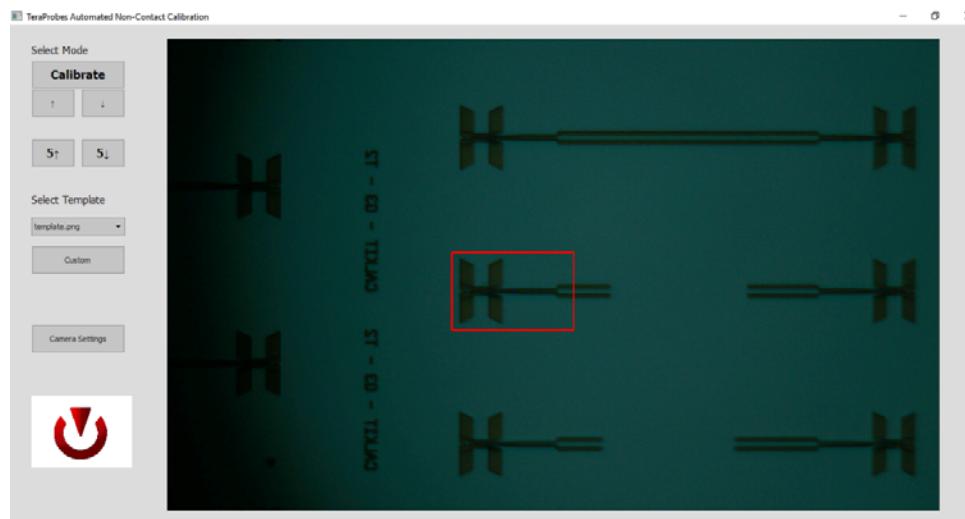
From concept...



... to Product

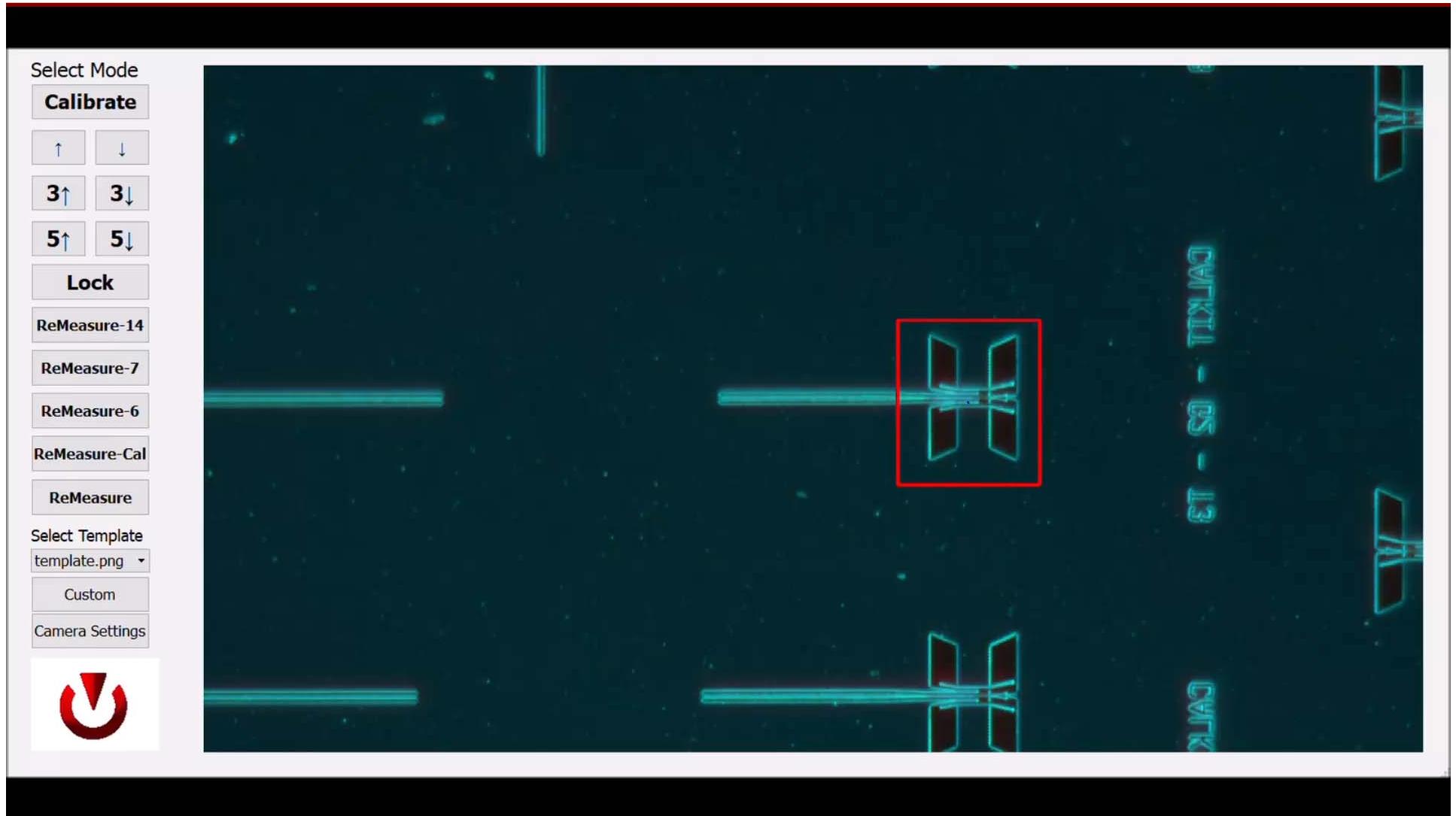


**Ohio**  
Third Frontier  
Innovation Creating Opportunity

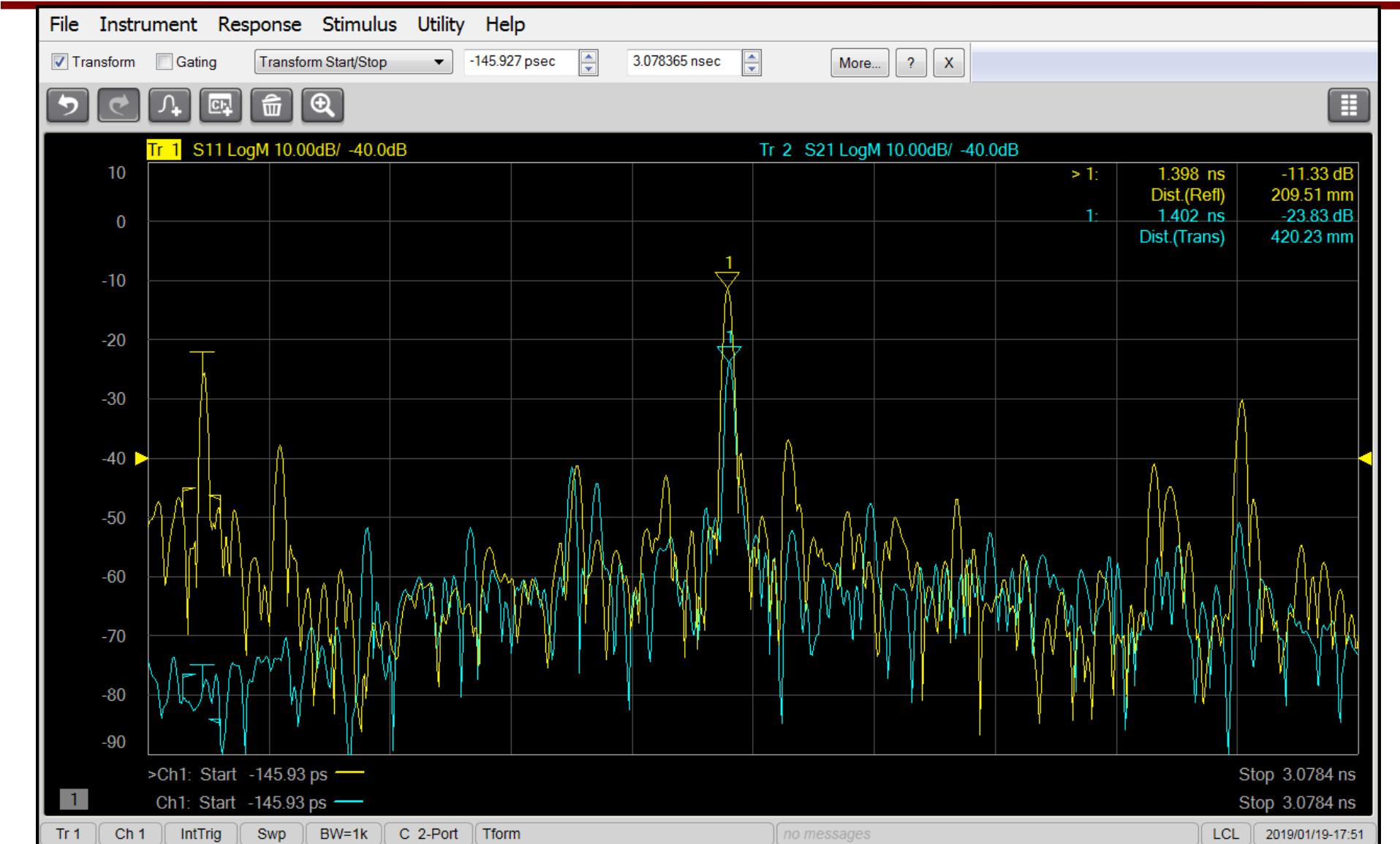


- Fully-automated
- Non-contact
- On-wafer / Wafer-scale Device and IC Probing Systems
- 55GHz-1.1THz
- Single-ended or Pure Differential

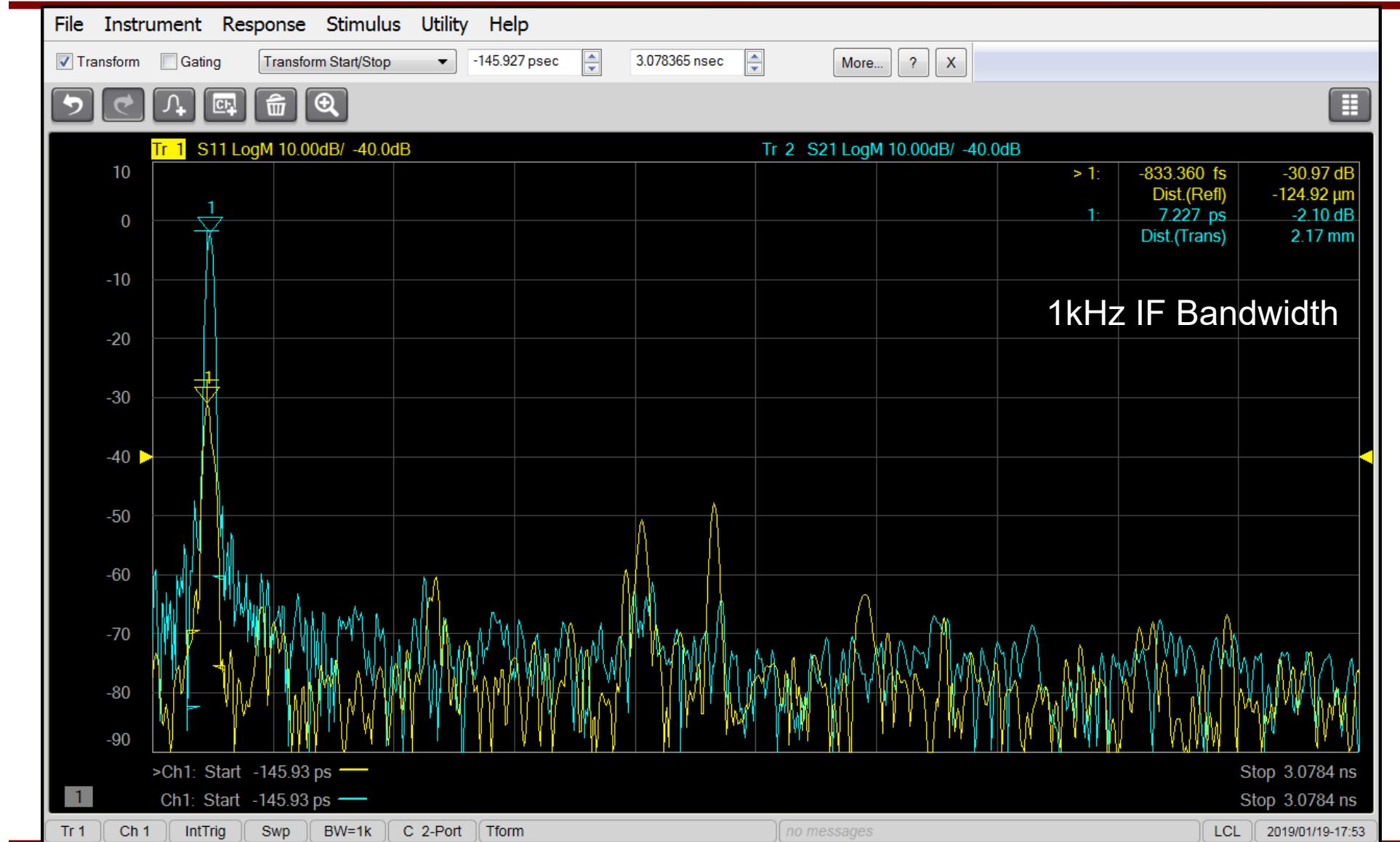
# Software-controlled Automation of Calibration and Measurements



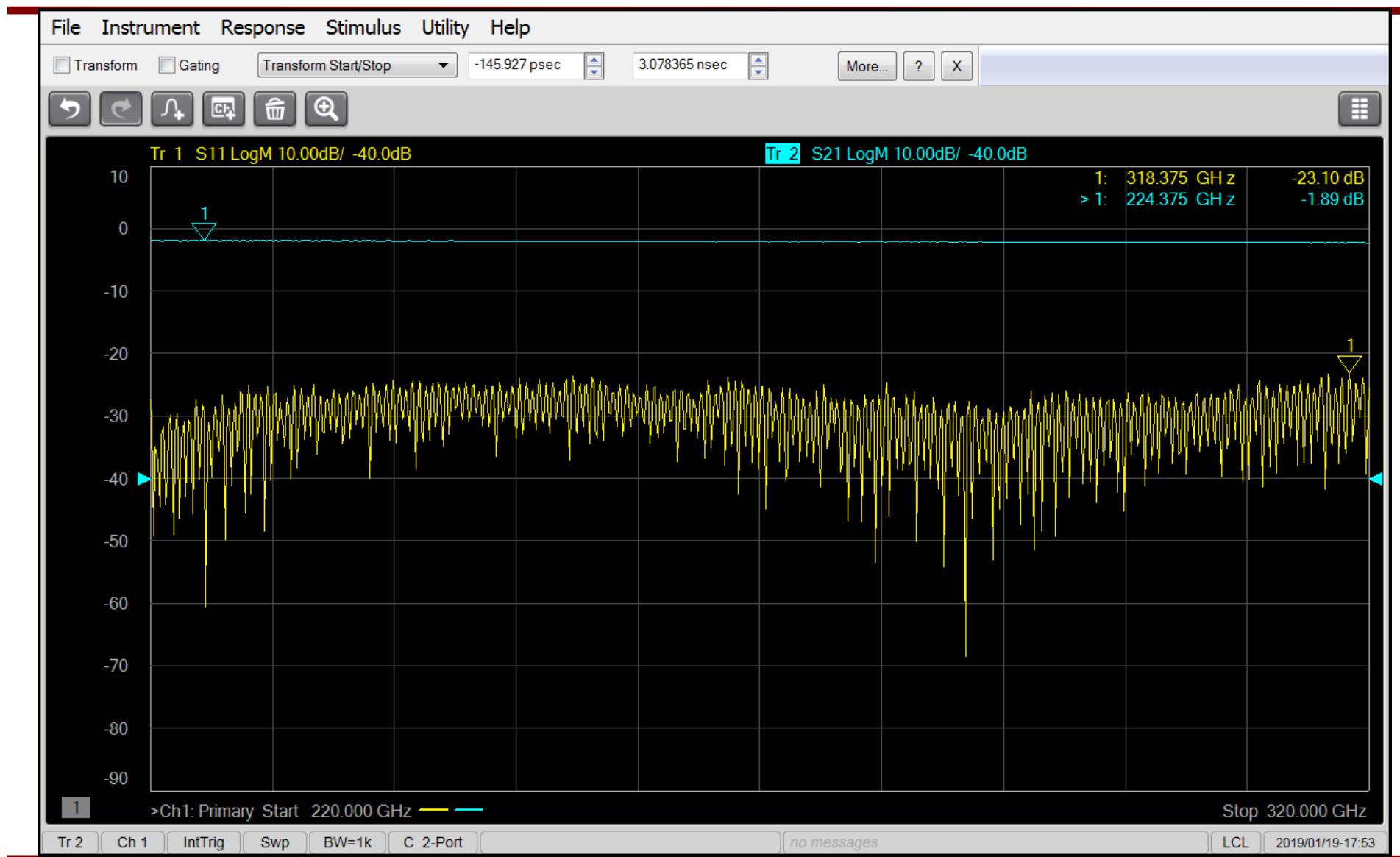
# Typical Response Before On-wafer Calibration: THRU (VNA first-tier calibrated to extender ports)



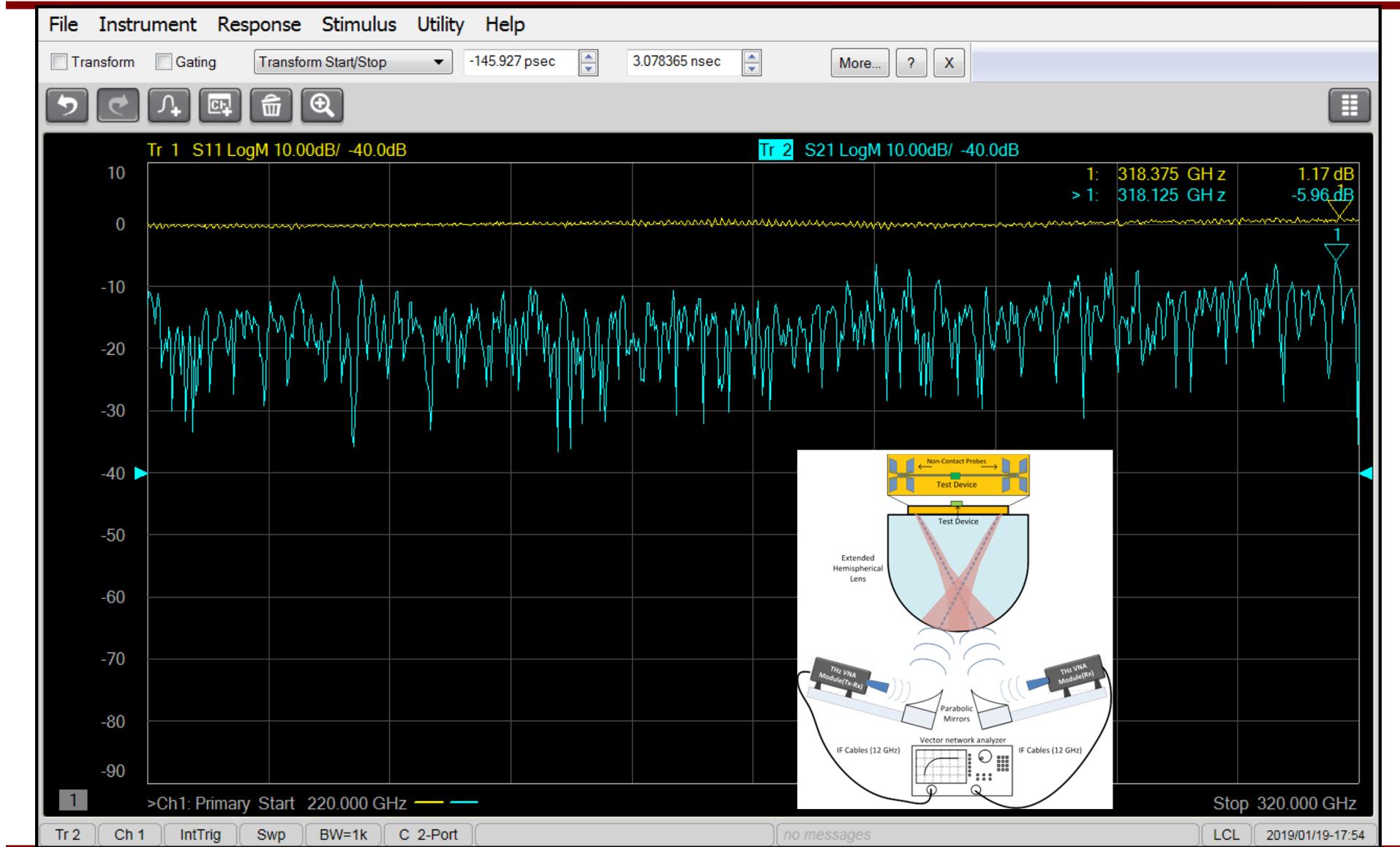
# Typical Response After On-wafer Calibration: THRU



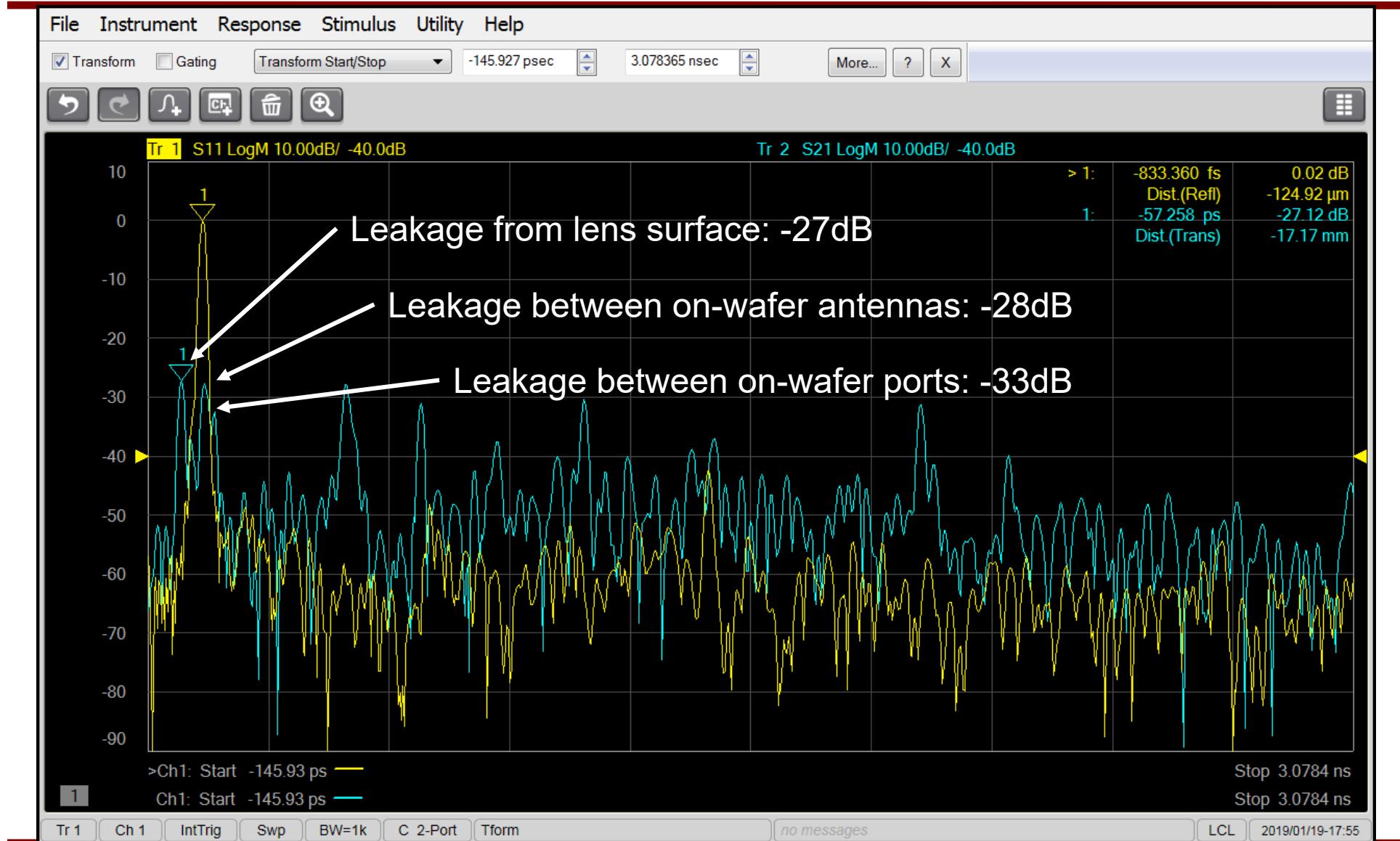
# On-wafer Calibrated THRU Response: Frequency Domain



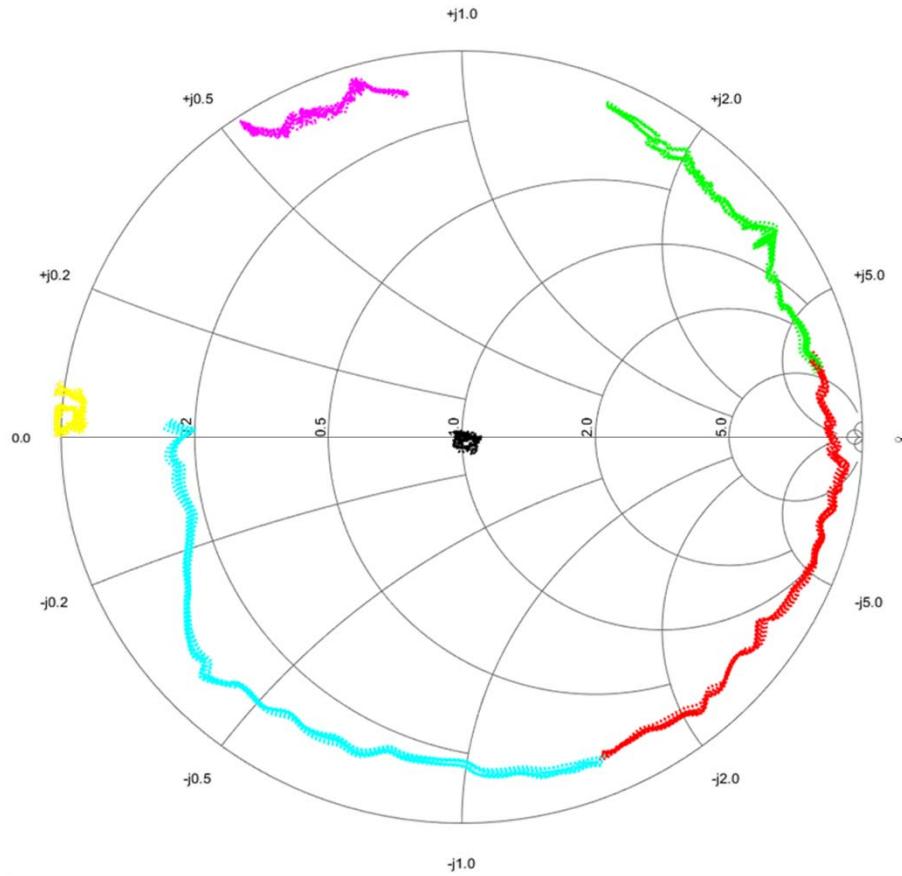
# On-wafer Calibrated SHORT Response: Frequency Domain



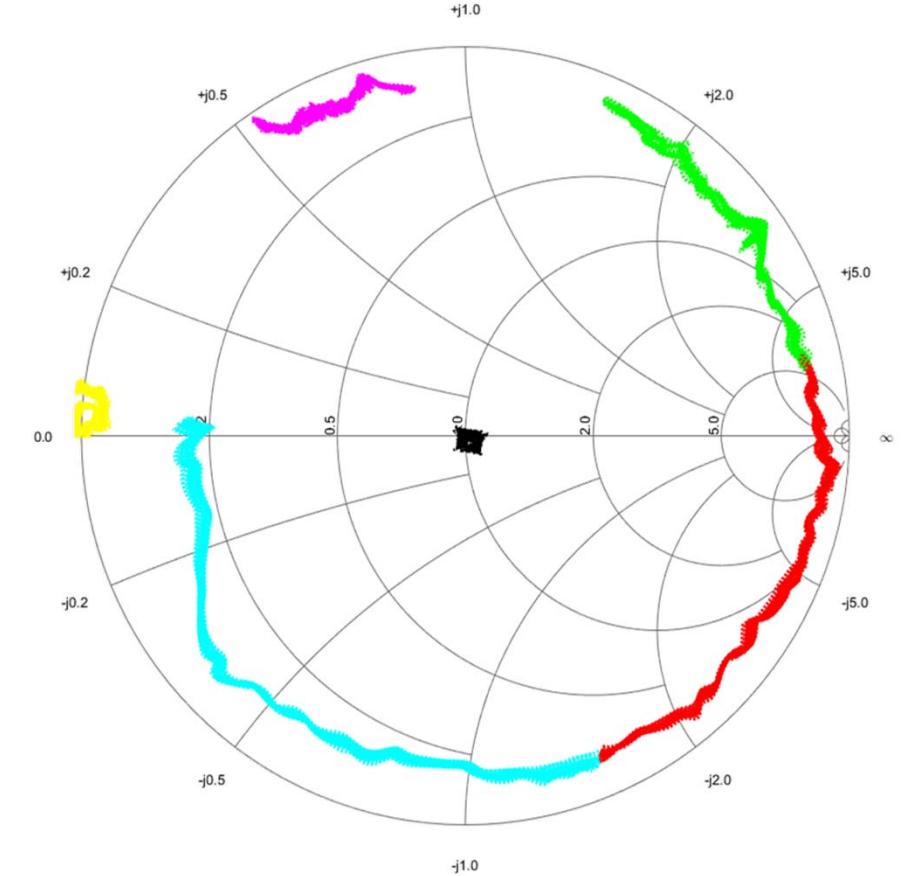
# On-wafer Calibrated SHORT Response: Time Domain



# Automated Repeatability – Calibration (WR3.4)



10 successive measurements conducted  
in the 220-330GHz band



40 successive measurements

# Automated Repeatability



Cal. Standards	10 Measurements		20 Measurements		30 Measurements		40 Measurements	
Stan. Dev. ( $\sigma$ )	Mag (%)	Phase (°)						
Ref. Short	0.80	0.37	0.68	0.35	0.68	0.38	0.70	0.37
Ref.+d	0.76	0.43	0.72	0.59	0.74	0.58	0.71	0.60
Ref.+2d	0.92	0.67	0.87	0.62	0.99	0.62	1.12	0.62
Ref.+3d	0.98	0.10	0.82	0.12	0.85	0.15	0.96	0.17
Ref.+4d	0.34	0.70	0.35	0.61	0.35	0.63	0.31	0.64
Overall Mean	0.76	0.45	0.69	0.46	0.72	0.47	0.76	0.48
Overall $\sigma$	0.25	0.25	0.20	0.22	0.24	0.21	0.31	0.21

## Repeatability at instrument drift levels:

- After an initial 20-min. warmup using VDI WR3.4 SOLT calibration kit
- VDI WR3.4 Extenders: 0.6% in amplitude and 0.42 degrees in phase over 20 min.